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(19) **United States**(12) **Patent Application Publication**
KAMIYA(10) **Pub. No.: US 2015/0155523 A1**(43) **Pub. Date: Jun. 4, 2015**(54) **ORGANIC ELECTROLUMINESCENCE
DISPLAY DEVICE**(52) **U.S. CL.**
CPC **H01L 51/5253** (2013.01)(71) Applicant: **Japan Display Inc.**, Tokyo (JP)(72) Inventor: **Akinori KAMIYA**, Tokyo (JP)(73) Assignee: **Japan Display Inc.**(21) Appl. No.: **14/559,960**(22) Filed: **Dec. 4, 2014**(30) **Foreign Application Priority Data**

Dec. 4, 2013 (JP) 2013-251216

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H01L 51/52 (2006.01)(57) **ABSTRACT**

The organic electroluminescence display device has a circuit board, an element layer which contains an organic electroluminescence film and a positive electrode and a negative electrode sandwiching the organic electroluminescence film and which is formed on the circuit board, and a sealing film sealing the element layer. The sealing film contains an inorganic layer covering the element layer and an organic layer formed between a part of the element layer and a part of the inorganic layer. The upper surface of the element layer has an inorganic contact area contacting the inorganic layer and an organic contact area contacting the organic layer. The organic contact area is a hollow in the upper surface of the element layer. The area of the upper surface of the organic layer is smaller than the area of the lower surface contacting the inner surface of the hollow.

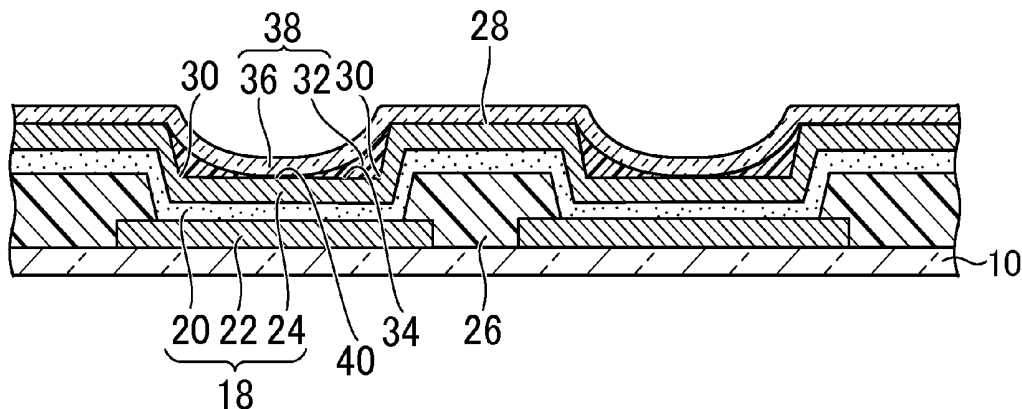


FIG.1

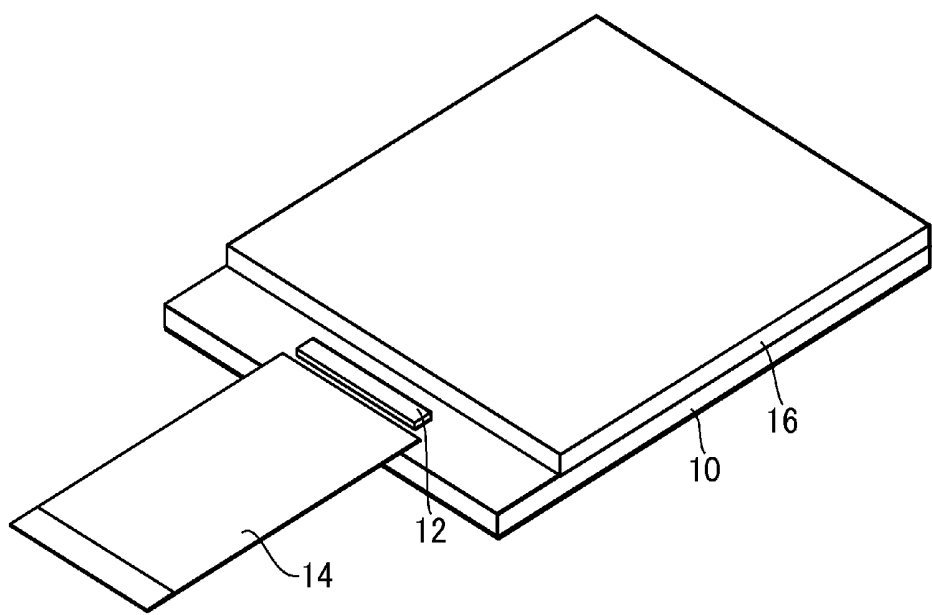
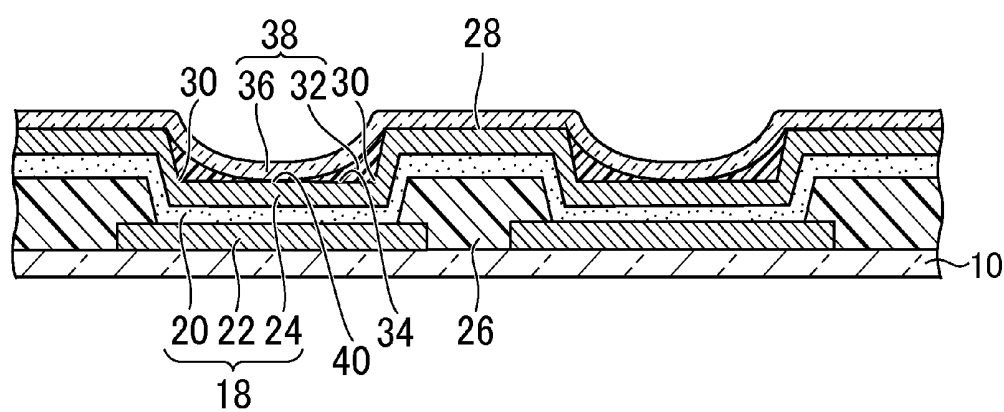


FIG.2



ORGANIC ELECTROLUMINESCENCE DISPLAY DEVICE

CROSS-REFERENCE TO RELATED APPLICATION

[0001] The present application claims priority from Japanese application JP2013-251216 filed on Dec. 4, 2013, the content of which is hereby incorporated by reference into this application.

BACKGROUND OF THE INVENTION

[0002] 1. Field of the Invention

[0003] The present invention relates to an organic electroluminescence display device.

[0004] 2. Description of the Related Art

[0005] Organic electroluminescence display apparatuses require a sealed structure for isolating the organic EL (Electro-Luminescence) film such as the light-emitting layer from the air. For example, a structure in which a multilayer sealing film containing an organic film of a resin sandwiched between inorganic films is used for sealing the organic EL film is known (Japanese Patent No. 4303591).

[0006] Although a high barrier property can be obtained with a structure in which the sealing film has an organic film, there has been a problem in that light is easily refracted at the boundary surface between the organic film and an inorganic film because the refractive indexes of these films are significantly different. In addition, when an organic film, which easily absorbs water, is continuously provided, there has been a problem in that water easily permeates and spreads.

SUMMARY OF THE INVENTION

[0007] An object of the invention is to provide a sealing film which maintains a high barrier property and in which the refraction of light and the spread of water can be prevented.

[0008] (1) The organic electroluminescence display device according to the invention is characterized by having: a circuit board; an element layer which contains an organic electroluminescence film and a positive electrode and a negative electrode sandwiching the organic electroluminescence film and which is formed on the circuit board; and a sealing film sealing the element layer: in which the sealing film contains an inorganic layer covering the element layer and an organic layer formed between a part of the element layer and a part of the inorganic layer; the upper surface of the element layer has an inorganic contact area contacting the inorganic layer and an organic contact area contacting the organic layer; the organic contact area is a hollow in the upper surface of the element layer; and the area of the upper surface of the organic layer is smaller than the area of the lower surface contacting the inner surface of the hollow. According to the invention, because the organic layer fills the hollow in the element layer, the inorganic layer can be formed on a surface with less unevenness and a high barrier property can be achieved. The refraction of light can be prevented in the inorganic contact area because there is no organic layer having a high refractive index, and the spread of water can be prevented because the organic layer is discontinuously provided.

[0009] (2) The organic electroluminescence display device of (1) may be characterized in that the positive electrode is two or more pixel electrodes under the organic electroluminescence film and the negative electrode is a common electrode on the organic electroluminescence film.

[0010] (3) The organic electroluminescence display device of (2) may be characterized in that the upper surface of the element layer has the inorganic contact area and the organic contact area in an area over each of the pixel electrodes.

[0011] (4) The organic electroluminescence display device of (2) or (3) may be characterized by further having an insulating layer formed between an edge of each of the pixel electrodes and the common electrode, in which the upper surface of the element layer has a protruding part along the shape of the insulating layer, and the hollow is formed from a low area which is over each of the pixel electrodes and is adjacent to the protruding part to an area rising to form the protruding part.

[0012] (5) The organic electroluminescence display device of any one of (1) to (4) may be characterized in that the organic contact area is completely surrounded by the inorganic contact area.

BRIEF DESCRIPTION OF THE DRAWINGS

[0013] FIG. 1 is a perspective view of an embodiment of the organic electroluminescence display device according to the invention.

[0014] FIG. 2 is a cross-section showing an embodiment of the circuit board in detail.

DETAILED DESCRIPTION OF THE INVENTION

[0015] Embodiments of the invention are explained below referring to the drawings. FIG. 1 is a perspective view of an embodiment of the organic electroluminescence display device according to the invention.

[0016] As shown in FIG. 1, the organic electroluminescence display device has a circuit board 10. On the circuit board 10, an integrated circuit chip 12 for driving an element for displaying an image is provided. A flexible wiring substrate 14 is connected to the circuit board 10 for electrically connecting the circuit board 10 to an external device.

[0017] The display device has an opposite substrate 16. The opposite substrate 16 is provided in such a way that it faces the circuit board 10 at a distance. The opposite substrate 16 may be a color filter substrate. Although it is not shown in the drawings, the opposite substrate 16 is attached to the circuit board 10 with a fill agent filled in an area surrounded by a damming material.

[0018] FIG. 2 is a cross-section showing an embodiment of the circuit board 10 in detail. An element layer 18 is provided on the circuit board 10. The element layer 18 contains an organic electroluminescence film 20. The organic electroluminescence film 20 contains a hole transport layer (not shown in the drawings).

[0019] The hole transport layer can be formed using metal phthalocyanine such as copper phthalocyanine and copper tetra(t-butyl) phthalocyanine, metal-free phthalocyanine, a quinacridone compound, an aromatic amine low-molecular hole injection transport material such as 1,1-bis(4-di-p-tolylaminophenyl)cyclohexane, N,N'-diphenyl-N,N'-bis(3-methylphenyl)-1,1'-biphenyl-4,4'-diamine and N,N'-di(1-naphthyl)-N,N'-diphenyl-1,1'-biphenyl-4,4'-diamine, a high-molecular hole transport material such as poly(paraphenylene vinylene) and polyaniline, a polythiophene oligomer material, or other known hole transport materials.

[0020] After forming the hole transport layer, an organic light-emitting layer (not shown in the drawings) is formed. The organic light-emitting layer is a layer that emits light

when electric current flows, and the organic light-emitting material forming the organic light-emitting layer may be a material that is generally used as an organic light-emitting material. Examples thereof are known fluorescent low-molecular materials capable of emitting light from the singlet state such as materials of coumarin, perylene, pyran, anthrone, porphyrin, quinacridone, N,N'-dialkyl-substituted quinacridone, naphthalimide and N,N'-diaryl-substituted pyrrolopyrrole, and known phosphorescent low-molecular materials capable of emitting light from the triplet state such as rare-earth metal complexes.

[0021] After forming the organic light-emitting layer, an electron transport layer (not shown in the drawings) is formed. The material of the electron transport layer may be a material that is generally used as an electron transport material. Examples thereof are low-molecular materials of triazole, oxazole, oxadiazole, silole, boron and the like, and the electron transport layer can be formed by a vacuum vapor deposition method.

[0022] As the method for forming the hole transport layer, the organic light-emitting layer and the electron transport layer, a vacuum vapor deposition method is used for a deposition-type material, and a known film formation method such as a nozzle printing method, a spin coating method, a slit coating method, an ink-jet method or a letterpress printing method can be used for a coating-type material.

[0023] The element layer 18 contains two or more pixel electrodes 22 (positive electrodes). As the material of the pixel electrodes 22, a transparent electrode material such as ITO (a composite oxide of indium and tin), IZO (a composite oxide of indium and zinc), tin oxide, zinc oxide, indium oxide and a composite oxide of aluminum oxide can be used. In this regard, ITO (indium tin oxide) is preferable because of its low resistance, resistance to solvents, transparency or the like. The pixel electrodes 22 are formed by film-forming of ITO by a sputtering method.

[0024] The element layer 18 also contains a common electrode 24 (negative electrode). As the material of the common electrode 24, for example, a transparent electrode material such as ITO, IZO, tin oxide, zinc oxide, indium oxide and a composite oxide of aluminum oxide, or the like can be also used, though the material is not limited to these examples. An example of the method for forming the common electrode 24 (negative electrode) is a formation method by a sputtering method.

[0025] In this regard, the present embodiment has a constitution in which the hole transport layer, the organic light-emitting layer and the electron transport layer have been laminated between the pixel electrodes 22, which are positive electrodes, and the common electrode 24, which is a negative electrode, from the side of the pixel electrodes 22. It is possible to apply a laminate structure in which layers such as a hole blocking layer and an electron injection layer selected if necessary have been laminated in addition to the hole transport layer and the organic light-emitting layer between the pixel electrodes 22 and the common electrode 24. Furthermore, the same formation methods as for the hole transport layer, the organic light-emitting layer and the negative electrode layer can be used for forming these layers.

[0026] The organic electroluminescence film 20 is sandwiched between the pixel electrodes 22 (positive electrodes) and the common electrode 24 (negative electrode). The pixel

electrodes 22 are under the organic electroluminescence film 20. The common electrode 24 is on the organic electroluminescence film 20.

[0027] An insulating layer 26 is between an edge of each of the pixel electrodes 22 and the common electrode 24. The contact (short circuit) of the pixel electrodes 22 and the common electrode 24 can be prevented by the insulating layer 26. The insulating layer 26 is formed using a photosensitive material by a photolithography method. Specifically, a photosensitive resin composition is coated on the circuit board 10 and a partitioned pattern is formed by pattern-exposure and development. The insulating layer 26 is formed using a resin composition in such a way that the light-emitting area corresponding to each pixel is divided, and the insulating layer 26 is formed to cover an edge of one of the pixel electrodes 22 for example.

[0028] The upper surface of the element layer 18 has a protruding part 28 along the shape of the insulating layer 26. A hollow 30 is formed in the upper surface of the element layer 18 from a low area which is over each of the pixel electrodes 22 and is adjacent to the protruding part 28 to an area rising to form the protruding part 28.

[0029] An organic layer 32 is provided in the hollow 30. The organic layer 32 is formed from an acrylic resin, polyethylene terephthalate or the like and can be formed by optional appropriate processes including a vacuum process such as vapor deposition, sublimation and a combination thereof and a coating process such as a nozzle printing method, a spin coating method, a slit coating method, an ink-jet method, a letterpress printing method, an intaglio offset printing method and a letterpress reverse offset printing method. The organic layer 32 is polymerized by applying UV after the film formation.

[0030] The upper surface of the element layer 18 has an organic contact area 34 contacting the organic layer 32. The organic contact area 34 is in an area over each of the pixel electrodes 22. The organic contact area 34 is the hollow 30 in the upper surface of the element layer 18. The area of the upper surface of the organic layer 32 is smaller than the area of the lower surface contacting the inner surface of the hollow 30.

[0031] An inorganic layer 36 is formed on the organic layer 32. For example, an SiN, SiO or SiON film is formed by a plasma CVD method. In case of SiN, an SiN film is formed by generating plasma in a mixed gas of SiH₄, NH₃ and N₂ during the film formation. The thickness of the SiN film is 400 nm and the film formation is conducted at a substrate temperature of 100° C. or lower.

[0032] The inorganic layer 36 can be formed by optional appropriate processes including conventional vacuum processes such as sputtering, vapor deposition, sublimation, CVD (chemical vapor deposition), PECVD (plasma-enhanced chemical vapor deposition), ECR-PECVD (electron cyclotron resonance plasma-enhanced chemical vapor deposition) and a combination thereof.

[0033] A sealing film 38 sealing the element layer 18 is constituted by the inorganic layer 36 and the organic layer 32. The sealing film 38 contains the organic layer 32. The organic layer 32 is between a part of the element layer 18 and a part of the inorganic layer 36. The organic contact area 34 is completely surrounded by an inorganic contact area 40. The sealing film 38 also contains the inorganic layer 36. The inorganic layer 36 is formed to cover the element layer 18. The upper surface of the element layer 18 has the inorganic contact area

40 contacting the inorganic layer 36. The inorganic contact area 40 is in an area over each of the pixel electrodes 22.

[0034] By thus forming the sealing film 38 by a two-layer structure unlike the conventional three-layer structure, it is possible to shorten the time and cut the cost for the sealing step and the subsequent step for exposing terminals.

[0035] According to the embodiment, because the organic layer 32 fills the hollow 30 in the element layer 18, the inorganic layer 36 can be formed on a surface with less unevenness and a high barrier property can be achieved. The refraction of light can be prevented in the inorganic contact area 40 because there is no organic layer 32 having a high refractive index, and the spread of water can be prevented because the organic layer 32 is discontinuously provided.

[0036] While there have been described what are at present considered to be certain embodiments of the invention, it will be understood that various modifications may be made thereto, and it is intended that the appended claims cover all such modifications as fall within the true spirit and scope of the invention.

What is claimed is:

1. An organic electroluminescence display device comprising:
 - a circuit board;
 - an element layer which contains an organic electroluminescence film and a positive electrode and a negative electrode sandwiching the organic electroluminescence film and which is formed on the circuit board; and
 - a sealing film sealing the element layer,
 wherein the sealing film contains an inorganic layer covering the element layer and an organic layer formed between a part of the element layer and a part of the inorganic layer;

the upper surface of the element layer has an inorganic contact area contacting the inorganic layer and an organic contact area contacting the organic layer; the organic contact area is a hollow in the upper surface of the element layer; and the area of the upper surface of the organic layer is smaller than the area of the lower surface contacting the inner surface of the hollow.

2. The organic electroluminescence display device of claim 1,
- wherein the positive electrode is two or more pixel electrodes under the organic electroluminescence film and the negative electrode is a common electrode on the organic electroluminescence film.
3. The organic electroluminescence display device of claim 2,
- wherein the upper surface of the element layer has the inorganic contact area and the organic contact area in an area over each of the pixel electrodes.
4. The organic electroluminescence display device of claim which further has an insulating layer formed between an edge of each of the pixel electrodes and the common electrode,
- wherein the upper surface of the element layer has a protruding part along the shape of the insulating layer, and the hollow is formed from a low area which is over each of the pixel electrodes and is adjacent to the protruding part to an area rising to form the protruding part.
5. The organic electroluminescence display device of claim 1,
- wherein the organic contact area is completely surrounded by the inorganic contact area.

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专利名称(译)	有机电致发光显示装置		
公开(公告)号	US20150155523A1	公开(公告)日	2015-06-04
申请号	US14/559960	申请日	2014-12-04
[标]申请(专利权)人(译)	株式会社日本显示器		
申请(专利权)人(译)	日本展示INC.		
当前申请(专利权)人(译)	日本展示INC.		
[标]发明人	KAMIYA AKINORI		
发明人	KAMIYA, AKINORI		
IPC分类号	H01L51/52		
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优先权	2013251216 2013-12-04 JP		
外部链接	Espacenet USPTO		

摘要(译)

有机电致发光显示装置具有电路板，包含有机电致发光膜的元件层和夹在有机电致发光膜上并形成在电路板上的正电极和负电极，以及密封元件层的密封膜。密封膜包含覆盖元件层的无机层和在元件层的一部分与无机层的一部分之间形成的有机层。元件层的上表面具有与无机层接触的无机接触区域和与有机层接触的有机接触区域。有机接触区域在元件层的上表面中是中空的。有机层的上表面的面积小于与中空的内表面接触的下表面的面积。

